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AMENDMENTS TO THE CLAIMS

Please add or amend the claims to read as follows, and cancel without prejudice or disclaimer to resubmission in a divisional or continuation application claims indicated as cancelled:

- 1. (currently amended) A method of erasing one or more non-volatile memory ("NVM") cells comprising: applying to the one or more NVM cells an erase pulse having a substantially [[non-constant]] non-flat voltage profile.
- 2. (original) The method according to claim 1, wherein the voltage profile of the erase pulse is predefined.
- 3. (original) The method according to claim 2, wherein the erase pulse has a voltage profile selected from the group consisting of ramp-like, trapezoidal, exponential-growth-like, asymptote-like and stepped
- 4. (original) The method according to claim 3, wherein the erase pulse is applied to each subset of a set of NVM cells in a staggered sequence.
- 5. (original) The method according to claim 1, wherein the voltage profile of the erase pulse is dynamically adjusted based on feedback.
- 6. (original) The method according to claim 5, wherein the feedback comes from a sensor selected from the group consisting of a current sensor, a voltage sensor, a current derivative sensor, and a voltage derivative sensor.
- 7. (original) The method according to claim 1, wherein the voltage of the erase pulse is adjusted in an inverse relation to current measure by the current sensor
- 8. (original) The method according to claim 1, wherein the voltage of the erase pulse is adjusted at a rate correlated to a signal produced by the current derivative sensor.

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- 9. (currently amended) A circuit for erasing one or more non-volatile memory ("NVM") cells comprising: an erase pulse source to produce an erase pulse having a substantially [[nonconstant]] non-flat voltage profile.
- 10. (original) The circuit according to claim 9, wherein said erase pulse source comprises a charge-pump.
- 11. (original) The circuit according to claim 10, wherein the erase pulse source is adapted to produce an erase pulse having a voltage profile selected from the group consisting of ramplike, trapezoidal, exponential-growth-like, asymptote-like and stepped.
- 12. (original) The circuit according to claim 9, further comprising a cell select circuit adapted to select to which cells of a set of NVM cells the erase pulse is applied
- 13. (original) The circuit according to claim 12, wherein said cell select circuit is adapted to apply the erase pulse to each sub-set of the set of NVM cells in a staggered sequence
- 14. (original) The circuit according to claim 9, further comprising a sensor to sense a characteristic of the erase pulse as it is being applied to the one or more NVM cells
- 15. (original) The circuit according to claim 14, wherein the sensor is selected from the group consisting of a current sensor, a voltage sensor, a current derivative sensor, and a voltage derivative sensor.
- 16. (original) The circuit according to claim 9, further comprising a controller to cause the erase pulse source to adjust the voltage profile of the erase pulse based on a signal from said sensor.
- 17. (original) The circuit according to claim 16, wherein said controller causes the voltage of the erase pulse to be adjusted in an inverse relation to current measure by the current sensor.

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18. (original) The circuit according to claim 16, wherein said controller causes the voltage of the erase pulse to be adjusted at a rate correlated to a signal produced by the current derivative sensor.

19. (currently amended) A system for erasing one or more non-volatile memory ("NVM") cells comprising: A NVM array, and an erase pulse source to produce an erase pulse having a substantially [[non-constant]] non-flat voltage profile.